

QUERY CONTROL FORM		RTIS USE ONLY	
Application No. <u>10031163</u>	Prepared by <u>M. RUTIA</u>	Tracking Number <u>05938013</u>	
Examiner-GAU <u>CARIASO 2875</u>	Date <u>5-13-4</u>	Week Date <u>4-19-4</u>	
	No. of queries <u>2</u>	<u>IPW</u>	

JACKET			
a. Serial No.	f. Foreign Priority	k. Print Claim(s)	p. PTO-1449
b. Applicant(s)	g. Disclaimer	l. Print Fig.	q. PTOL-85b
c. Continuing Data	h. Microfiche Appendix	m. Searched Column	r. Abstract
d. PCT	i. Title	n. PTO-270/328	s. Sheets/Figs
e. Domestic Priority	j. Claims Allowed	o. PTO-892	t. Other

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FORM: PTO-1449
(REV: 7-80)U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICEAny Docket N :
2001-0827.00

Serial No:

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(37 CFR 1.98(b))

(use several sheets if necessary)

Applicant:
Christopher HillFiling Date:
August 27, 2002

Group:

31046 U.S. PTO
10/229445
08/27/02

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass
	AA				
	AB				
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FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation Yes	Translation No
	AO						
	AP						
	AQ						

Initial

OTHER ART (including author, title, date, pertinent pages, etc.)

AKS	AR		"Synthese and characterization of aerosol silicon nanocrystal nonvolatile floating-gate memory device", M.L. Ostraat et al., Applied Physics Letters, Volume 79, Number 3, July 16, 2001, pages 433-435.
AKS	AS		"Ultraclean Two-Stage Aerosol Reactor for Production of Oxide-Passivated Silicon Nanoparticles for Novel Memory Devices", Michele L. Ostraat et al., Journal of The Electrochemical Society; 148 (5), Pages G265-G270

Examiner:

Asok Kumar Sarkar

Date Considered:

3/17/2004

EXAMINER:

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